



Bestler, Booth, Ream, Helmick, Miller, Johannisson, Hollman  
Schorling, Marty, Kopecki, McFarland, Lange, Mullane, Gunderson

#### ACTIVE MEMBERS

Paul Bestler  
William G. Booth  
Kenneth Eberly  
Allen H. Helmick  
Walter G. Hollman  
Walter E. Gunderson  
Sven Johannisson

Alfred Kapecki  
J. Russell Lang  
Rolland McFarland  
Raymond W. Marty  
John H. Miller  
Daniel J. Mullane  
Altus M. Ream

Robert H. Schorling

In addition to the forty-seven collegiate chapters there are seventeen professional chapters situated in the principal cities of the country. A feature of the fraternity is a placement bureau maintained by these professional chapters to aid graduates in securing work.

Candidates are elected twice a year from the senior, junior and sophomore classes in Chemical Engineering. Election is based on scholarship, ability and personality.

